

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Jerome M. Eldridge et al.

Title: ATOMIC LAYER DEPOSITION OF METAL OXIDE AND/OR LOW ASYMMETRICAL TUNNEL
BARRIER INTERPOLY INSULATORS

Docket No.: 1303.045US1
Filed: February 20, 2002
Examiner: Tu-Tu Ho
Customer No.: 73115

Serial No.: 10/081,818
Due Date: N/A
Group Art Unit: 2818
Confirmation No.: 3148

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

We are transmitting herewith the following attached items (as indicated with an "X"):

X Supplemental Information Disclosure Statement (2 pgs.).

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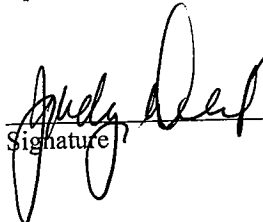
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CERTIFICATE UNDER 37 CFR 1.8: The undersigned hereby certifies that this correspondence is being filed using the USPTO's electronic filing system EFS-Web, and is addressed to: Mail Stop Amendment Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on this 7th day of November, 2008.


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